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## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Kwang Su Choe, et al.

Examiner: Marianne L. Padgett

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Confirmation No: 4796

Commissioner for Patents P. O. Box 1450 Alexandria, VA 22313-1450

## **RESPONSE UNDER 37 C.F.R. § 1.116**

Sir:

In response to the Office Action dated October 1, 2008, please consider the following amendments and remarks with respect to the above referenced application.

## **CERTIFICATE OF ELECTRONIC FILING**

I hereby certify that this correspondence is being electronically filed with the United States Patent and Trademark Office e-business website on the date listed below.

Dated: November 24, 2008

Leslie S. Szivos